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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant : Meng-Hung CHEN et al. Confirmation No: 5022  
Appl. No. : 10/816,820  
Filed : April 5, 2004  
Title : 3-STAGE METHOD FOR FORMING DEEP TRENCH  
STRUCTURE AND DEEP TRENCH CAPACITOR  
TC/A.U. : 1765  
Examiner : DEO, DUY VU NGUYEN  
  
Docket No.: : CHEN3650/REF  
Customer No: : 23364

**AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of November 16, 2005, in connection with the above-identified application. This response is timely filed.

Please amend the application as follows:

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.